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Inhomogeneous superconductivity and quasilinear magnetoresistance at amorphous LaTiO₃/SrTiO₃ interfaces

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Abstract

We have studied the transport properties of LaTiO₃/SrTiO₃ (LTO/STO) heterostructures. In spite of 2D growth observed in reflection high energy electron diffraction, transmission electron microscopy images revealed that the samples tend to amorphize. Still, we observe that the structures are conducting, and some of them exhibit high conductance and/or superconductivity. We established that conductivity arises mainly on the STO side of the interface, and shows all the signs of the two-dimensional electron gas usually observed at interfaces between STO and LTO or LaAlO₃, including the presence of two electron bands and tunability with a gate voltage. Analysis of magnetoresistance (MR) and superconductivity indicates the presence of spatial fluctuations of the electronic properties in our samples. That can explain the observed quasilinear out-of-plane MR, as well as various features of the in-plane MR and the observed superconductivity.

Keywords: oxide interfaces, inhomogeneous superconductivity, magnetotransport properties

 Supplementary material for this article is available [online](#)

(Some figures may appear in colour only in the online journal)

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1. Introduction

Since the discovery of conductivity [1] at the interface between the two nonmagnetic band insulators LaAlO₃ (LAO) and SrTiO₃ (STO), oxide interfaces have been under intense investigation. The dominant view in the literature on the origin of conductivity at the (001) LAO/STO interface is the so-called polar catastrophe scenario [2, 3], based on the difference between the stacking of neutral layers in STO, but one-electron-charged layers in LAO. To avoid the discontinuity at the interface, half an electron per unit cell has to transfer from the LAO surface down to interface, leading to a formation of two-dimensional electron liquid (2DEL). Besides that, also La/Sr intermixing [4] and oxygen vacancies formed in the STO [5, 6] can lead to the creation of the conducting layer. Moreover, it was proposed recently that the development of a critical density of oxygen vacancies at the surface of the LAO layer plays a vital role in avoiding polar discontinuity [3, 7].

Along with LAO/STO, also the interface between the antiferromagnetic Mott insulator LaTiO₃ (LTO) and STO has been under intensive investigation. LTO is polar along (001) crystal direction, so a charge transfer similar to LAO/STO may be expected. At the LTO/STO interface, the polar discontinuity can be resolved by the variable valence of Ti [8, 9]. Indeed, Biscaras *et al* [10] argued that conductance at this interface is on the STO side, similar to LAO/STO. On the other hand, Wong *et al* [11] proposed that the LTO layer is metallic when grown on STO, due to a lattice distortion induced by stress. La/Sr intermixing [12–15], and oxygen and lanthanum off-stoichiometry [16] can also lead to conductivity in LTO.

A recurring problem in the growth of LTO is that it easily suffers from strong overoxidation, both due to migration of oxygen from STO and to oxidation in air of uncapped films [17]. Such overoxidation leads to defective or even amorphous films [17–19]. Interfaces between STO and amorphous oxides were shown to be conducting due to oxygen vacancies formed on the surface of STO [20–22], and, similar to the stoichiometric crystalline interfaces [23, 24], the amorphous interfaces are also superconducting [25, 26].

In this paper, we have studied LTO/STO interfaces grown by pulsed laser deposition (PLD), and found that in spite of layer-by-layer growth signatures, the LTO layer tends to amorphize. Still, the conductivity in the system is basically due to a 2DEL formed on the STO side of the interface. The 2DEL properties are not much different from those of other STO-based oxide interfaces. In particular, Hall data show two-band behavior with standard values for the carrier concentrations, and back-gating shows the presence of a Lifshitz point. Less normal is quasilinear magnetoresistance (MR), and non-uniform superconductivity. We argue that the possible origin of these phenomena is the non-uniform distribution of oxygen vacancies on the STO surface due to the uncontrolled oxidation process in the LTO layer, which leads to spatial inhomogeneities. This inhomogeneity is clearly seen in the superconducting state, but not easily discernible in the normal state, which is an important part of the message.

2. Experimental details

LTO layers were grown by PLD on a TiO₂-terminated surface of STO(001) single crystal substrates. The growth temperature was 750 °C. Growth was in an O₂ atmosphere utilizing two nominal pressures: 1×10^{-4} and 5×10^{-4} mbar. The thickness of the samples was determined by observing the intensity oscillations using reflection high energy electron diffraction (RHEED) and fixed at 10 u.c. (see figure 1(a)). The RHEED pattern showed characteristic stripes indicating 2D growth (figures 1(b) and (c)). Magnetotransport measurements in the range 3–300 K were performed with a physical properties measurement system (a PPMS) from quantum design, and below 1 K in an Oxford instruments Triton dilution refrigerator. Samples were wirebonded with Al wire for magnetotransport measurements, and measured with a standard lock-in technique. Scratches were made on the samples by a diamond knife in the center of each edge to ensure the current path through the sample center, as shown schematically in the inset figure 1(d), together with a denumeration of the contacts. Notwithstanding the observation of RHEED oscillations, results of scanning transmission electron microscopy (STEM) reveal that the LTO layer in our samples is amorphous (see inset in figure 1(e)). This is probably due to a relatively high oxygen growth pressure, which, as mentioned, leads to overoxidation and defective or even amorphous films [17–19]. Indeed we observe a decaying intensity of RHEED oscillations (figure 1(a)) and cloudiness in the RHEED pattern besides the stripes, which already indicates on some amorphization process. Since the necessary oxygen for overoxidation, at least in part, comes from the substrate, it appears that the amorphisation process takes place during deposition of initially crystalline layers.

Most of the measurements were performed in the van der Pauw (VDP) geometry. To determine the sheet resistance, two resistances were measured, one called R_{hor}/H with the current applied over one edge (contacts A, B) and the voltage measured along the opposite edge (contacts C, D), and one called R_{ver} using the other pair of edges (current through A, D, voltage over B,C). The sheet resistance R_S was then calculated by solving the VDP equation for R_S by the Newton–Raphson method:

$$e^{-\pi R_{\text{ver}}/R_S} + e^{-\pi R_{\text{hor}}/R_S} = 1. \quad (1)$$

The MR was determined in the same way, by either applying in-plane or out-of-plane fields. Hall data were obtained by injecting the current along one diagonal and measure the voltage across the other one, using an out-of-plane field. The out-of-plane magnetotransport data were (anti-)symmetrized. The in-plane data were not. Instead, the two measured voltages in in-plane geometry were used to obtain MR with the current parallel and perpendicular to the current direction. The experimental data obtained at temperatures below 1 K were smoothed to remove noise except for the measurements in magnetic field. The geometry for the measurements of the superconducting transition in the Triton is described in section 4. An extra sample was prepared for study by STEM, using an oxygen pressure of 5×10^{-4} mbar. The conductivity

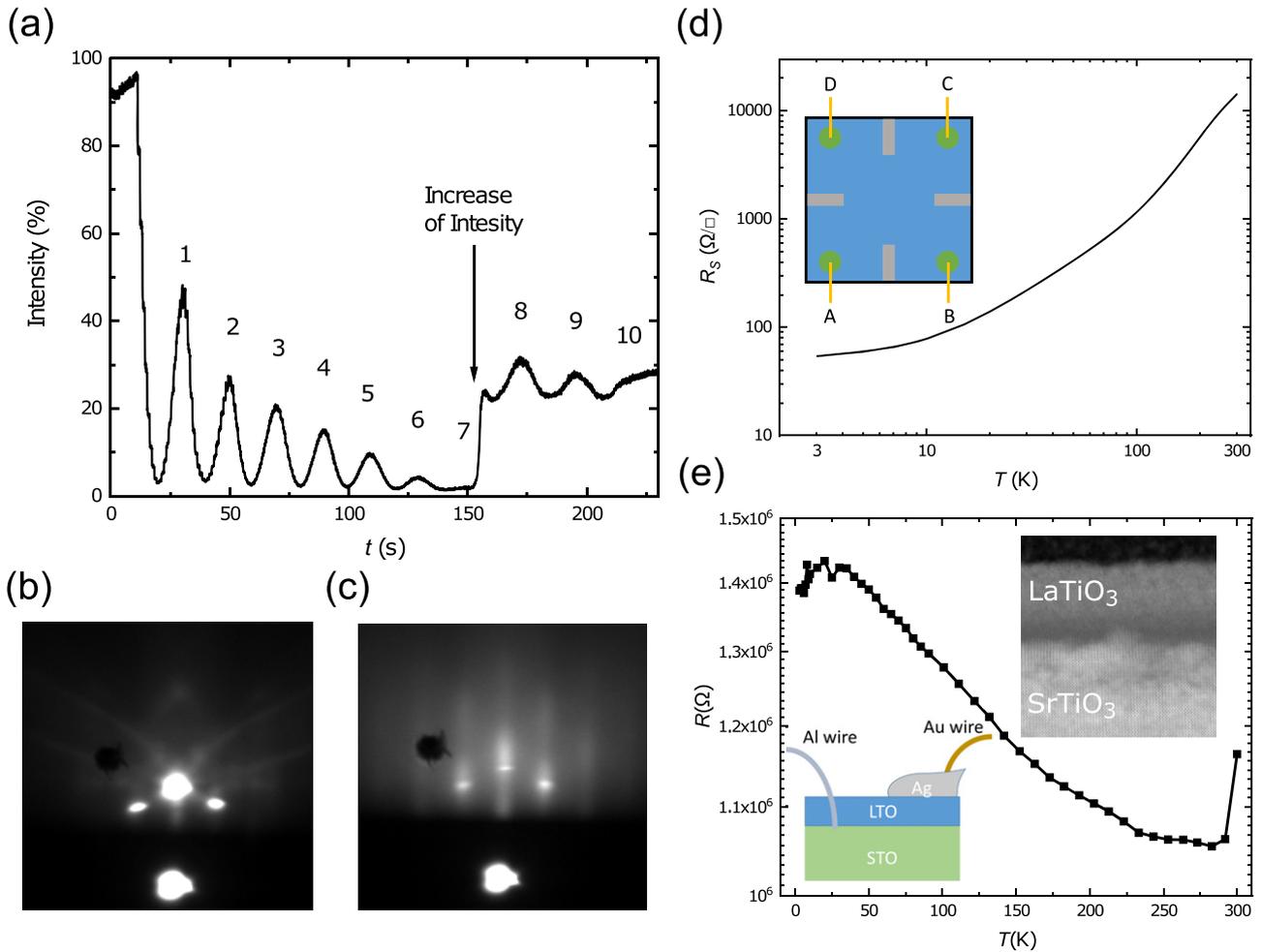


Figure 1. (a) RHEED intensity monitoring during grown 10 u.c. of LTO. RHEED patterns (b) before and (c) after deposition. (d) Temperature dependence of sheet resistance. Insert: sketch of VDP measurements. (e) Temperature dependence of the two-probe measured resistance of the LTO layer. Schematics of two-probe measurement and STEM scan of the LTO/STO interface are shown in the inserts.

of the LTO layer was checked by using additional gold wires, which were glued by silver paint to the surface of the sample, and resistance was measured by a source meter with an applied current of $1 \mu\text{A}$ in a two-probe geometry.

3. Normal state magnetotransport

3.1. The origin of conductance

The different samples did show a variation in conducting properties. Some exhibit higher conductance and/or superconductivity. We did not observe a correlation between high conductance or superconductivity and the oxygen pressure during growth. The transport data reported here is on a sample which shows high conductivity, a decrease of the sheet resistance upon lowering the temperature (figure 1(d)) with a large residual resistivity ratio $\text{RRR} = R_S(300 \text{ K})/R_S(10 \text{ K}) = 261$, and superconductivity below 300 mK. This sample has been grown at 5×10^{-4} mbar akin to the sample used for the STEM study.

As mentioned above, the conductance in these heterostructures can arise not only from a 2DEL forming at the STO/LTO interface but also in the LTO itself. To distinguish between

these two possibilities, after performing the transport measurements presented below, we investigated the conductivity of the LTO layer in the following manner. An Au wire was glued by the silver paint to the LTO surface as is shown schematically in the inset in figure 1(e). Resistance measurements as function of temperature between the Al wire contact and the Au wire contact, shown in figure 1(e), demonstrated that although the LTO layer is slightly conducting, it exhibits insulating behavior going to lower temperatures. That conductance could arise due to the formation of pinholes in the LTO film under the surface of silver paint [27]. Because the LTO layer is (almost) insulating and amorphous, we conclude that the conductivity in our samples arise from oxygen vacancies on the surface of STO similar to the previously reported conducting interfaces between amorphous oxide and STO [19–22]. This can explain the high RRR but also the variation of conducting properties observed from sample to sample.

3.2. Magnetotransport without back gate

Broadly speaking, the magnetotransport properties are similar to previously reported results on oxide heterostructures. In

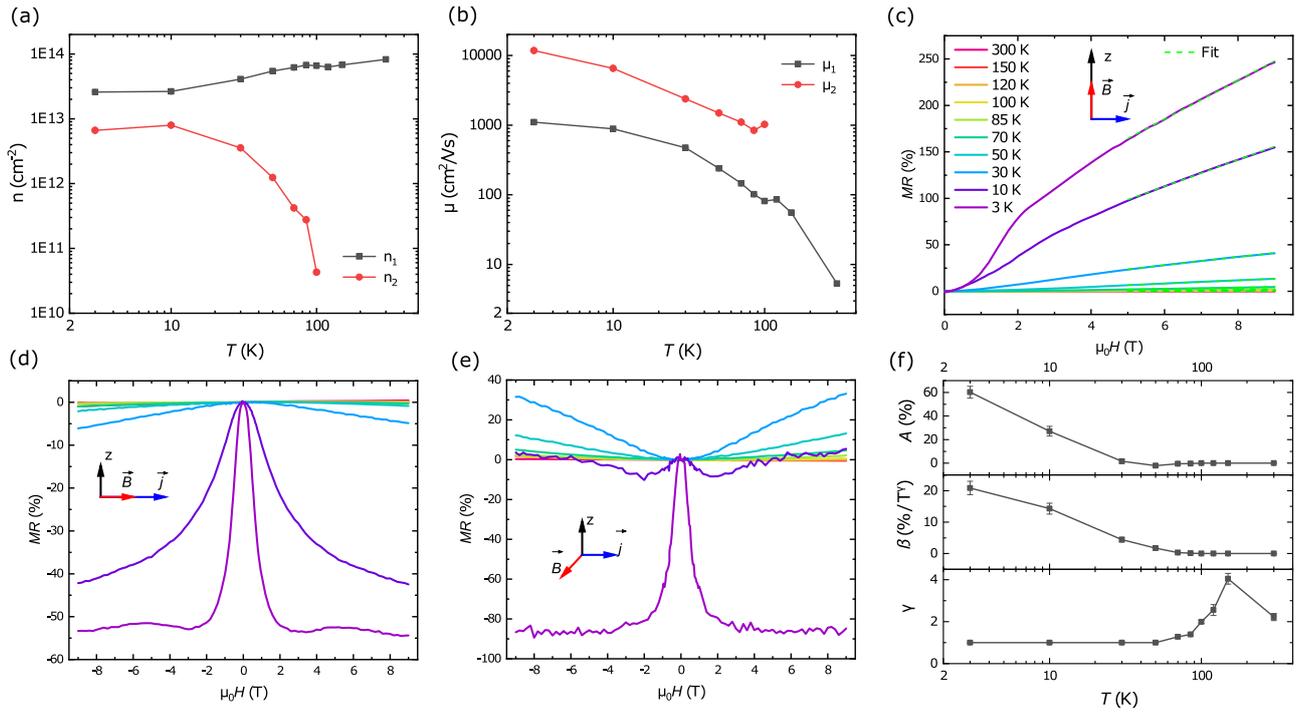


Figure 2. (a) Carrier concentration and (b) mobility versus temperature obtained from a two-band analysis of Hall resistance measurements (given in the supplement). (c)–(e) The MR with magnetic field oriented (c) perpendicular to the sample plane, (d) in-plane parallel to the current direction, and (e) in-plane perpendicular to the current direction. (f) Temperature dependence of the parameters to describe the non-linear out-of-plane MR by fitting equation (2).

particular the Hall resistance becomes non-linear below 100 K, marking the appearance of two-band behavior, with two types of carriers: of high concentration and low mobility, and vice versa. The Hall data and details of the Hall analysis are given in the supplement, extracted carrier concentrations and mobilities in figures 2(a) and (b). The out of plane MR is anomalous. It is almost flat at high temperatures, and in low fields gradually becomes parabolic with lower temperature. So far, such behavior is similar to most of the results on STO-based interfaces. However, below 70 K, a quasilinear MR in high fields starts to develop (figure 2(c)), with values much higher than reported previously in LTO/STO [28]. To describe this behavior, we fitted the MR in the field range from 5 T to 9 T with the following equation:

$$MR = A + \beta B^\gamma, \quad (2)$$

where A, β, γ are fitting parameters. The results of the fit are shown in figure 2(f). At high temperature where the MR is small, the parameters A and β are almost zero. At low temperatures, γ is smaller than 2, indicating that linear contribution to MR becomes dominant. Note that for this analysis, we limited the lowest boundary for γ to 1 in order to avoid unphysical behavior of A .

The in-plane MR is negligible at high temperatures (figures 2(d) and (e)). At low temperatures, the parallel-to-current configuration shows a negative MR, which increases at temperatures below 30 K and undergoes a transition from parabolic to bell shape. The perpendicular-to-current configuration exhibits first an increase of the positive MR down to 70 K, shows the onset of negatives lobes below 30 K and finally

transforms also to a bell shape with saturation at 3 K. Note that the VDP configuration does not allow to reliably exclude contributions to the MR of currents perpendicular to the magnetic field in the parallel in-plane geometry and currents parallel to the field in the perpendicular in-plane geometry.

3.3. The effect of gating on the sheet resistance

To further study the magnetotransport properties, we applied a back gate voltage V_{BG} to the sample. First we investigate the effect of a gate voltage on R_S . The ‘training’ of the sample at 3 K, meaning successive up-down sweeps of the voltage, (figure 3(a)) showed an increase of R_S in the backsweeps, which is usually explained as the trapping of charges escaping from the quantum well [29, 30]. We observe some hysteric effects between the up sweep and the subsequent down sweep which are not always present; moreover, we do not find the interface to become insulating in the backsweep at low or negative V_{BG} . This was found for highly conducting (crystalline) interfaces [24, 31], but not for less conducting ones [29, 30]. Figure 3(b) shows the temperature dependence of R_S , measured from 200 V down to -200 V. Coming from negative V_{BG} , the R_S shows an upturn to low temperatures which disappears at 0 V. Also, the change in R_S at low temperatures is largest between 0 V and 100 V, similar to what is seen in the training sweeps shown in figure 3(a). We will come back to this behavior in the discussion.

3.4. The effect of gating on the magnetotransport

Starting again with the Hall resistance, we find it becomes nonlinear between -25 and 0 V [supplement figure S2(b)

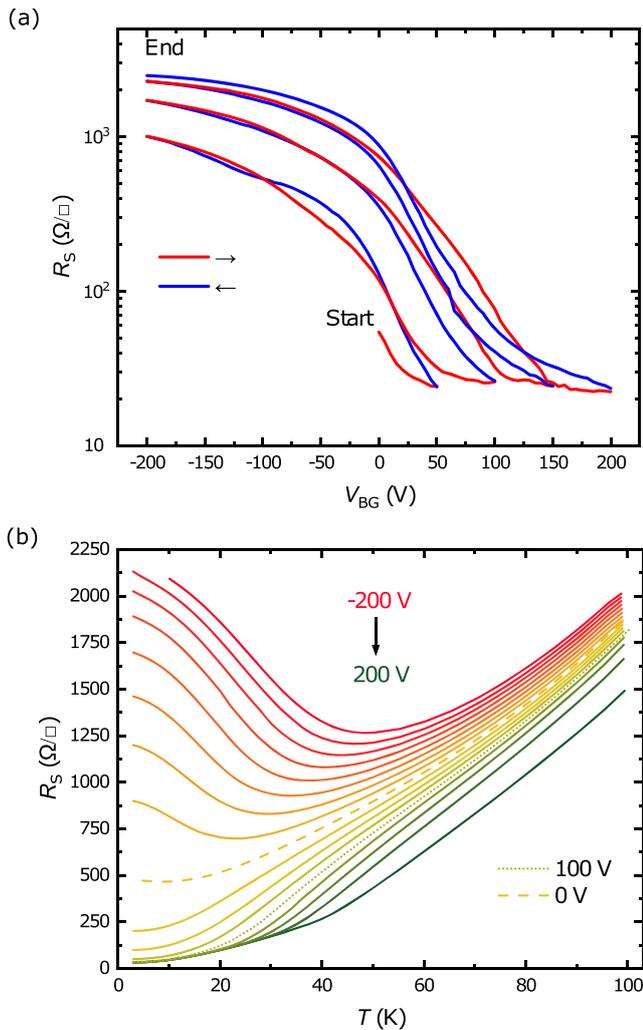


Figure 3. (a) Dependence of the sheet resistance R_S on the back gate voltage. (b) Temperature dependence of R_S for gate voltages from 200 to -200 V with steps of 25 V.

(<https://stacks.iop.org/JPCM/33/055001/mmedia>), signaling the well-known Lifshitz transition [32, 33]. The gate dependence of the carrier concentrations and mobilities, found after standard analysis, is given in figures 4(a) and (b). In the proximity of the transition, between -20 and 40 V, the two-band model gives an anomalous increase of carrier concentration and a dip in the mobility of the majority carriers, with high error bars. This is the case at 3 K, as well as at 0.5 K, with the measurements performed in a different cryostat. This anomaly probably arises due to a fast decrease in the second type of carriers, which the fit is not able to correctly describe; and to the fact that the mobility values in this regime are close, which complicates the fitting procedure. To avoid such problems, we limited the lowest possible mobility value of majority carriers in this region by the value extracted from one band analysis at the closest point to the transition. Such a limit resulted in a plateau of the mobility of majority carriers versus V_{BG} near the Lifshitz transition. Note also that the carrier concentrations of the two bands become almost equal above 100 V.

Turning to the MR at 3 K, the out-of-plane MR, shown in figure 4(c) (see supplement figure S2(a) for a zoom-in around

low fields and MR values), is small and negative in high fields at high negative gate voltages. In this range of V_{BG} , the parameters A and β are almost zero (figure 4(f)), and equation (2) is not always adequate to describe the high field MR; also γ shows inconsistent behavior. However, with an increase of the gate voltage, MR becomes positive, and above 50 V, the quasilinear MR at 3 K (figure 4(c)) starts to develop with the value of γ about 1 (figure 4(f)). At 0.5 K, equation (2) gives poorer fit with higher error bars and less clear gate dependence. That can be due to more noise in the data obtained in our low temperature cryostat due to low current used and smaller available field range ($[-8T, 8T]$). However, if we fix $\gamma = 1$ starting from 70 V, then the fit results are consistent (purple curves in figure 3(d)). Linear high field MR has been seen before in STO-based heterostructures [32, 34, 35].

The in-plane MR parallel to the current shows a transition from positive to negative at 0 V, whereas the in-plane MR perpendicular to the current stays negative (figures 4(d) and (e) and supplement figures S2(c) and (d)). Above 0 V, both in-plane configurations showed substantial enhancement of the negative MR and developed the bell shape field dependence (figures 4(d) and (e)). They exhibit saturation in high fields above 100 V, and the amplitude starts to decrease, especially in the configuration field parallel to the current.

Summarizing this part, the normal state properties show all the characteristics of the oxide 2DEL, with a high conductance due to a high carrier concentration, and a Lifshitz point around zero gate voltage. The MR is clearly sensitive to the Lifshitz point and in particular in the out-of-plane configuration shows quasi-linear behavior which needs to be discussed.

4. Electronic transport in the superconducting state

We studied the superconducting properties of the sample in the VDP geometry, using either the ‘horizontal’ or the ‘vertical’ sides, and for the whole range of gate voltages V_{BG} . We also measured in a two-probe configuration (current and voltage contacts on the same side). Those data are given in the supplement, figure S3. We find dissimilar behavior in the two VDP measurements, so we did not calculate a sheet resistance R_S by solving the VDP equation. Instead, we multiplied the measured resistance by the VDP constant $c_{VDP} = \frac{\pi}{\ln 2}$. In figure 5, we represent the data in two different ways. Figures 5(c) and (d) show $R_S(T)$ for gate voltage between -200 V and 200 V. Figures 5(e) and (f) shows R_S in a colorscale, as function of V_{BG} and T . In the vertical configuration, the resistive transition is more or less monotonous, as can be expected. T_c increases when V_{BG} is increased from -200 V, reaches a maximum around 0 V, and then decrease again. At the same time, R_S decreases continuously. The behavior of T_c at high V_{BG} can therefore be better followed in the colorscale plot, where it is shown as a dashed line marking a 50% drop from the resistance at 600 mK. In the horizontal configuration, the resistance around T_c is non-monotonous. For all V_{BG} , the resistance first rises before going down to 0. Comparing the color plots, both measurements show a dome shaped T_c behavior similar to

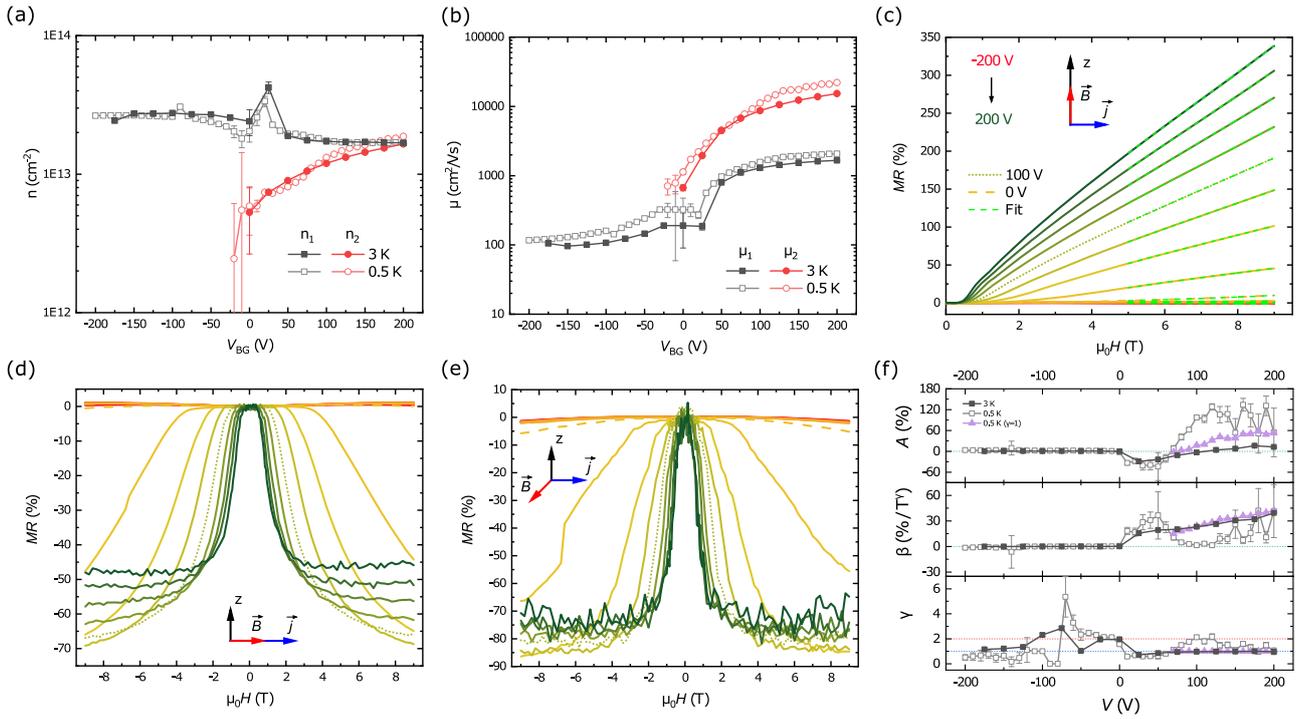


Figure 4. (a) Carrier concentration and (b) mobility versus gate voltage at the temperatures 3 K and 0.5 K as indicated, obtained from a two-band analysis of Hall resistance measurements. (c)–(e) The MR at 3 K with magnetic field oriented (c) perpendicular to the sample plane, (d) in-plane parallel to the current direction, and (e) in-plane perpendicular to the current direction. Note that -200 V is not shown for out-of-plane magnetic field measurements. (f) Temperature dependence of the parameters to describe the non-linear out-of-plane MR by fitting equation (2). Note that near transition from negative to positive high field MR in the range $[-110, -80]$ parameter γ and, for some values, β were fixed.

reported previously [24, 32], with a maximum around 0 V, but the maximum T_c is much lower in the horizontal configuration.

Anisotropy in STO-based structures has been reported before [25, 36]. It can arise, for instance, due to the formation of regions with different conducting properties, which strongly affects measurements in the VDP geometry. In a recent report on the effect of STO domain walls on the normal state resistance of mesoscopic LAO/STO devices, the authors of [37] proposed a scenario where a high resistance region develops in the center of the sample in order to explain the anisotropic behavior they observed. In our case, the behavior of $R(T)$ dependencies above 0.3 K does not differ significantly for both geometries, although some variation of the resistance is present. In the transition, however, the sample may well become inhomogeneous. The two-probe resistance behavior in the supplement shows indications of a percolative transition, and features we observe can be understood using a resistor model for an inhomogeneous superconductor adapted from reference [38]. The original model was precisely used to explain the peak in $R_S(T)$ for films measured in the VDP geometry [38]. A sketch of the equivalent electric circuit for the modified model, where all resistances have different transition temperatures, is shown in figure 1(b). The sample corners are designated as in the insert of figure 1(d). The algorithm to solve the equations is described in the supplement.

The normalized resistances at 0 V for the different measurement configurations, including the two-probe measurements, are plotted in figure 6(a). They can be divided into five

regions. In region I, the temperature is above T_c for all percolation paths, and all resistances are in the normal state. $R_{\text{VDP}}^{\text{ver}}$ (earlier called R_{ver}) decreases in region II and becomes zero in region III, while $R_{\text{VDP}}^{\text{hor}}$ (earlier called R_{hor}) reduces to zero in region III. In region IV, both two probe resistances become equal to each other and reach zero at the start of region V. Of course, multiple combinations of transition temperatures of R_i that lead to a very good fit of the data are shown in figure 6(c). The fits themselves are shown in figure 6(d). The table with fit parameters is included in the supplement.

In region II, R_2 goes to zero and, therefore, $R_{\text{VDP}}^{\text{ver}}$ goes to zero too. Also, the denominator decreases faster than the numerator in equation (S6) and consequently, $R_{\text{VDP}}^{\text{hor}}$ now increases. The opposite trend is observed for $R_{2\text{probe}}^{\text{hor}}$, whereas $R_{2\text{probe}}^{\text{ver}}$ changes insignificantly. In region III, R_5 and R_7 reduce to zero, and thereby $R_{\text{VDP}}^{\text{hor}}$ reduces to zero. In region IV, $R_2 = 0$, $R_5 = 0$ and $R_7 = 0$, as well as the measured resistances $R_{\text{VDP}}^{\text{hor}}$ and $R_{\text{VDP}}^{\text{ver}}$, and therefore $R_{2\text{probe}}^{\text{hor}}$ and $R_{2\text{probe}}^{\text{ver}}$ become equal:

$$R_{2\text{probe}}^{\text{hor}} = R_{2\text{probe}}^{\text{ver}} = \frac{R_1 R_3 R_4 R_6 R_8}{R_1 R_6 (R_3 R_4 + R_3 R_8 + R_4 R_8)}. \quad (3)$$

The resistances R_1 and R_6 , occurring as a product in both numerator and denominator, have to remain finite in the measured range, for equation (3) to be determinate. In region V, one of resistances R_3 , R_4 or R_8 is zero because the resistances

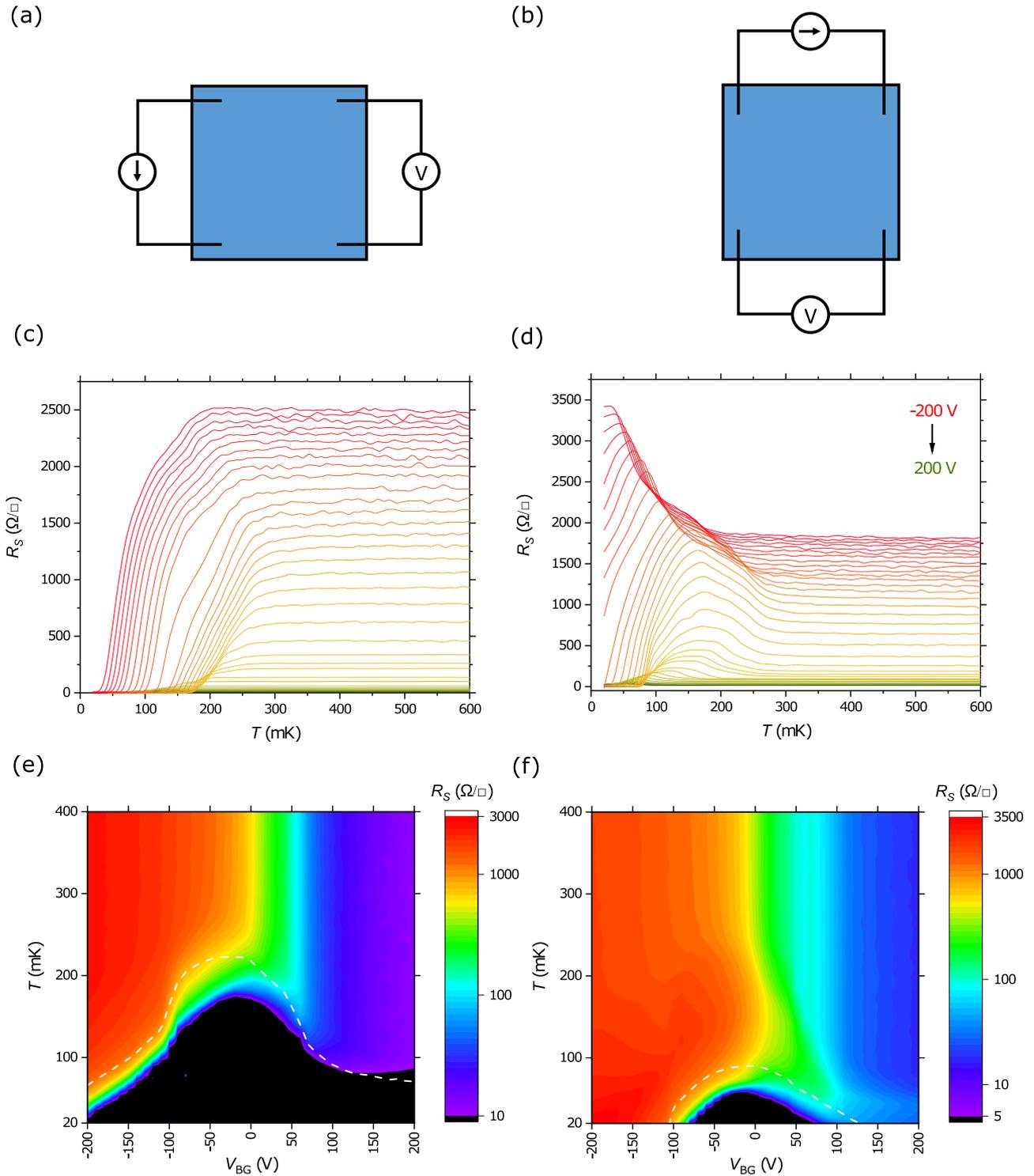


Figure 5. Behavior of the sheet resistance R_S as function of temperature T and back gate voltage V_{BG} for two VDP contact geometries called (a) ‘vertical’ and (b) ‘horizontal’. $R(T)$ curves at different gate voltage with step of 10 V for (c) vertical and (d) horizontal configurations. The same data visualized in color map form for (e) vertical and (f) horizontal configurations.

in the two-probe are zero. In our case, it is R_8 , whereas R_1 , R_3 , R_4 , and R_6 are assumed not to undergo a superconducting transition in the measured range of temperatures to stabilize the fit.

The behavior on both sides of the resistance dome around zero gate voltage, for our different measurement configura-

tions, can be understood from this model, assuming the T_c ’s of all percolation paths on both sides of the dome are suppressed by the gate voltage. For the VDP vertical configuration, because R_2 has the higher T_c , the resistance stays zero in the whole range of gate voltages. In the other configurations, since R_5 , R_7 and R_8 stay finite, T_c is (more) quickly

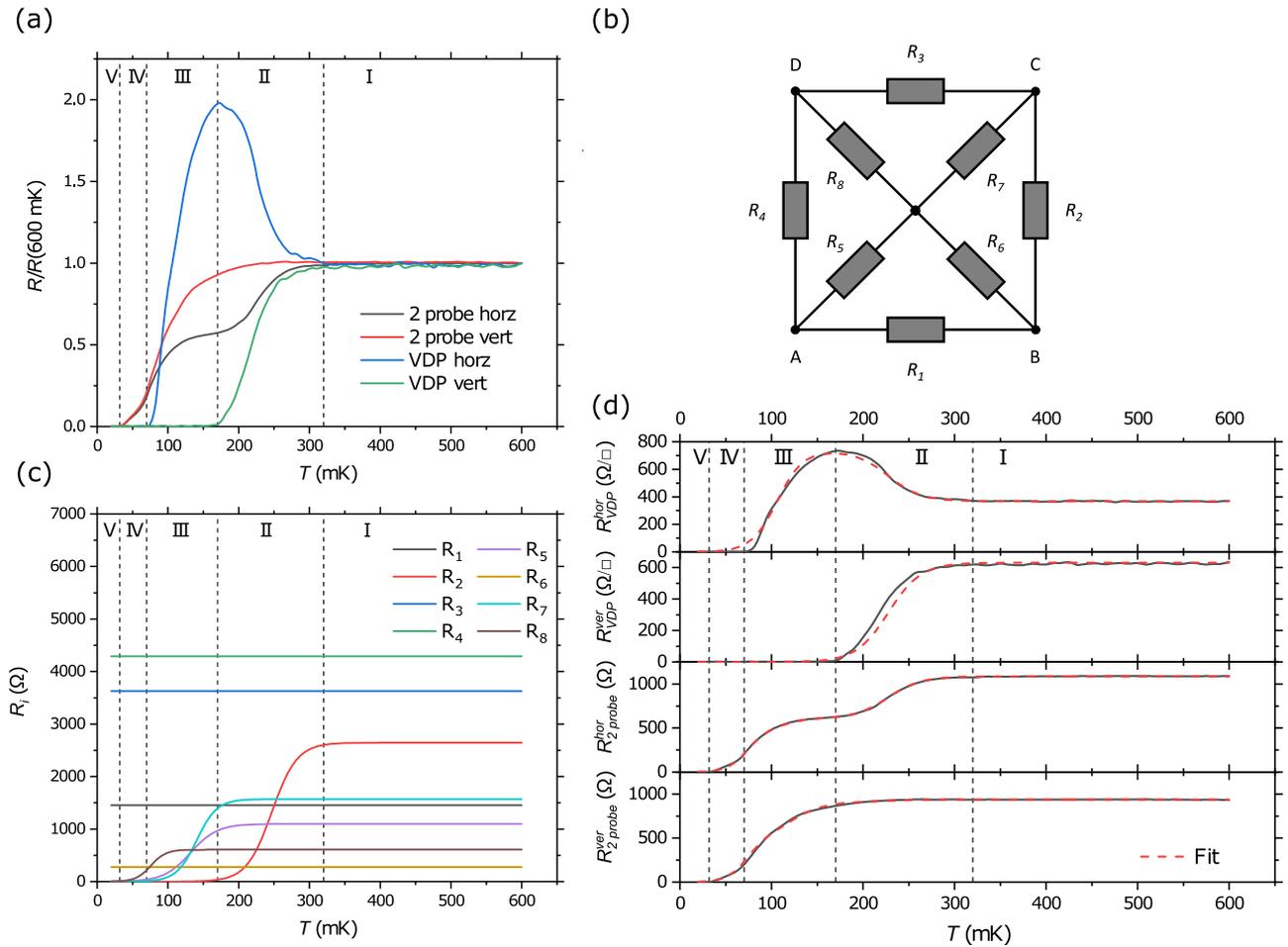


Figure 6. (a) The temperature dependent resistance for the different measurement configurations at 0 V, normalized to the normal state value just above the transition. (b) Temperature dependence of the different model resistors R_i (see text). (c) Resistance in different measured configurations and fit using equations (6)–(11) in supplementary.

suppressed, both in the VDP horizontal and in the two-probe configurations.

The proposed model also provides insight into the large critical currents observed in our sample, shown in supplement figure S4(f) and (g). The percolation paths for critical currents corresponding to R_2 , R_5 and R_7 have higher T_c . Therefore, a much higher induced current is required to drive those regions, which constitute the percolation paths, to the normal state in VDP configuration. T_c of the percolation path corresponding to R_8 is smaller, and a lower current to drive it in the resistive state is required in two-probe configuration.

5. Discussion

Results of the back gate experiments on our a-LTO/STO samples can be easily separated in three regions: (i) negative gate voltages, (ii) voltages between -20 V and $+75$ V, and (iii) above $+75$ V. In the first region, transport is governed by a one-band regime. Note that we do not observe an insulating state in the negative gate voltage range. This can be a sign of nonuniform conductivity. The behavior under voltage sweeps in the positive quadrant is another. We are apparently not able to fully trap the carriers and induce an insulating state

as can occur in (crystalline) LAO/STO and LTO/STO interfaces [29, 30]. Instead, we suggest that due to a significant non-uniformity of conducting properties, the trapping of electrons, which is seen in the hysteretic behavior, rearranges the current flow in the sample.

In the second regime the transport has changed to two band behavior. In this region, the MR exhibits the enhancement of out-of-plane and in-plane MR in agreement with previous works. Anisotropic in-plane MR has been reported in LAO/STO heterostructures [39–41]. This behavior has been attributed to the magnetic ordering [39, 41]. Simultaneously, our observation of a bell shape of the in-plane MR at different gate voltage is similar to the results obtained by Diez *et al* [42]. They argued (see also reference [43]) that the decrease in resistance, observed when the field is applied parallel to the plane and perpendicular to the current, can be described by a single particle Boltzmann equation. They showed that, when the second band is occupied, both interband scattering and spin-orbit coupling (SOC) are enhanced, which leads to the observed large negative in-plane MR. The MR is strongly modified in the gate region with the strongest SOC tunability, which would correspond to the region between 0 V and 75 V in our data. However, we also see an unexpected

enhancement in the geometry with current parallel to the field. We cannot exclude contribution of currents perpendicular to the field in this geometry, as mentioned in section 3.2, but another contribution may well arise from (spatial) mobility and carrier density fluctuations in our sample. In this region, T_c and I_c of superconducting state reach their maximum.

The high positive gate voltage range above 75 V is the range where the positive quasilinear MR develops which we believe is another signature of inhomogeneous transport in our films. In fact, such a crossover is observed in various different systems where spatial inhomogeneities can be invoked [44–48]. Generally, to observe the crossover at low fields requires relatively high mobilities. In our system these are available through high mobility carriers above the Lifshitz point.

Earlier, reference [40] argued that the large positive MR supports an electronic phase separation scenario. However, there is a significant difference for our films compared to the ones studied in reference [40, 41]. Our system does not (for gate voltages of 0 V and above) exhibit an upturn of sheet resistance at low temperatures. Even more below 30 K, the MR for field-perpendicular-current is always negative. The main reason for this is that the results reported in reference [40] were on crystalline LAO/STO samples grown at the high pressure of 10^{-2} mbar O_2 . Lower pressures leads to a decrease in the maximum magnetization according to results of reference [40], thus, making scenario of the phase separation between normal and magnetic region implausible as the main driving mechanism for the observed quasilinear MR.

At higher carrier densities (above 75 V), the in-plane MR showed a decrease, indicating an additional contribution which saturates in high fields. A connection between a non-trivial negative in-plane MR and a linear out-of-plane MR was actually observed in work on thin films of the Dirac semimetal Cd_3As_2 [49], and in electron doped GaAs quantum wells [50]. In both cases, the macroscopic disorder is argued to be the origin of such behavior of MR. Additional support for this scenario in our samples is that the quasilinear MR develops in the region where high and low-mobility carriers have very similar carrier concentration as shown in figure 4(a), and even appear to cross. So far, such crossing in STO-heterostructures has been only observed in experiments with top gate [33]. In Cd_3As_2 an increase of negative MR was observed in the temperature range where two electron-type carriers have a crossover. However, in our case, a negative MR in current-perpendicular-field is also expected to arise from SOC effects and interband scattering. Spatial fluctuations in the conductivity can result in the current paths perpendicular to the magnetic field in in-plane geometry with the current parallel to the field [46, 49]. Together with the imperfection of the geometry used in the sample, it can lead to the non-trivial MR for this configuration. Finally, also, the low temperature data point to the development of regions that do not become superconducting above 100 V and again indicate spatial fluctuations of conductivity.

Coming back to the superconductivity, extensive research already indicated the existence of inhomogeneous superconductivity in STO-based oxide heterostructures [26, 51–55]. As

we discussed the behavior of both $R(T)$ and $I(V)$ in our sample indicates the presence of strong spatial variations. The simple model we use to describe the inhomogeneous superconductor [38] can describe some of the main features of the superconducting transition and critical current behavior in our samples, although it is obviously too simple to be able to explain all the details of the real system, and in particular features arising due to a weak coupling between regions.

The final point to discuss is the possible origin of inhomogeneous electronic structure of the interface. This is the more important since it is often assumed that amorphous layers per se need not yield significantly different physics than crystalline layers. Previously, inhomogeneities in the conductance have been shown to arise from ferroelastic domains [56–60], which strongly affect superconducting properties [57, 61]. At the same time, as was mentioned, the quasilinear MR in our samples is much higher than in the crystalline LAO/STO system, indicating an additional significant source of inhomogeneities. A prime candidate is (oxygen) stoichiometry variations, most likely created during the growth. The amorphicity of the LTO layer itself may be an issue, but also the process of amorphization of LTO is not controlled in our samples, which can in particular be seen from the fact that RHEED oscillations were observed during growth. The structure of the interface may well be different from what is fabricated by room temperature deposition, and less straightforward to connect to the growth pressure. With respect to the amorphicity, it is instructive to note that also the deposition of amorphous LAO on STO led to a superconducting state which was described as a random array of Josephson-coupled superconducting domains [26].

6. Conclusions

We have grown and studied heterostructures of $LaTiO_3/SrTiO_3$. In spite of clear two-dimensional growth, our samples were found to be amorphous, which may be due to the absence of a capping layer. The samples showed the salient characteristics of the electron gas at oxide interfaces, in particular two-band behavior with normal values for the carrier concentrations and mobilities, as well as the existence of a Lifshitz point upon applying a gate voltage. The conductance was found to be high and inhomogeneous, signaled in particular by a large quasilinear MR and a percolative superconducting transition. By measuring in different configurations, both VDP and two-probe, and using a simple model for a non-uniform superconductor [38], we were able to explain prominent features of the superconducting transition in our sample. We propose that the non-uniformities arise from oxygen stoichiometry variations in our samples.

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